

L Number	Hits	Search Text	DB	Time stamp
398	1776	(align\$4 regist\$6) same (wafer mask reticle) same (xray x-ray (x adj ray))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/09 13:10
399	1433	((align\$4 regist\$6) with (wafer mask reticle)) same (xray x-ray (x adj ray))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/09 13:11
400	33	((align\$4 regist\$6) with (wafer mask reticle)) same (xray x-ray (x adj ray)) same ((project\$3 adj (screen display monitor)) screen display)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/09 13:35
401	1	"6381005".PN.	USPAT	2004/01/09 13:19
402	3	6252649.pn.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/09 13:21
403	539	((align\$4 regist\$6) with (wafer board) with (mask reticle photomask photomask (photo adj mask))) same (xray x-ray (x adj ray))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/09 13:48
404	4	((align\$4 regist\$6) with (wafer board) with (mask reticle photomask photomask (photo adj mask))) same (xray x-ray (x adj ray))) and 382/151.ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/09 13:42
405	2486	382/151.ccls. 250/559.3.ccls. 356/401.ccls. 356/614.ccls. 348/87.ccls. 348/95.ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/09 13:50
406	46	((align\$4 regist\$6) with (wafer board) with (mask reticle photomask photomask (photo adj mask))) same (xray x-ray (x adj ray))) and (382/151.ccls. 250/559.3.ccls. 356/401.ccls. 356/614.ccls. 348/87.ccls. 348/95.ccls.)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/09 13:50

L Number	Hits	Search Text	DB	Time stamp
398	1776	((align\$4 regist\$6) same (wafer mask reticle) same (xray x-ray (x adj ray)))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/09 13:10
399	1433	((align\$4 regist\$6) with (wafer mask reticle)) same (xray x-ray (x adj ray))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/09 13:11
400	33	((align\$4 regist\$6) with (wafer mask reticle)) same (xray x-ray (x adj ray)) same ((project\$3 adj (screen display monitor)) screen display)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/09 13:35
401	1	"6381005".PN.	USPAT	2004/01/09 13:19
402	3	6252649.pn.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/09 13:21
403	539	((align\$4 regist\$6) with (wafer board) with (mask reticle photomask photomask (photo adj mask))) same (xray x-ray (x adj ray))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/09 15:43
404	4	((align\$4 regist\$6) with (wafer board) with (mask reticle photomask photomask (photo adj mask))) same (xray x-ray (x adj ray))) and 382/151.ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/09 13:42
405	2486	382/151.ccls. 250/559.3.ccls. 356/401.ccls. 356/614.ccls. 348/87.ccls. 348/95.ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/09 13:50
406	46	((align\$4 regist\$6) with (wafer board) with (mask reticle photomask photomask (photo adj mask))) same (xray x-ray (x adj ray))) and (382/151.ccls. 250/559.3.ccls. 356/401.ccls. 356/614.ccls. 348/87.ccls. 348/95.ccls.)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/09 13:50
465	859	((align\$4 regist\$6) with (wafer board) with (mask reticle photomask photomask (photo adj mask))) same (xray x-ray (x adj ray) radiation)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/09 15:13
466	86	((align\$4 regist\$6) with (wafer board) with (mask reticle photomask photomask (photo adj mask))) same (xray x-ray (x adj ray) radiation)) and (382/151.ccls. 250/559.3.ccls. 356/401.ccls. 356/614.ccls. 348/87.ccls. 348/95.ccls.)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/09 15:14
467	40	((align\$4 regist\$6) with (wafer board) with (mask reticle photomask photomask (photo adj mask))) same (xray x-ray (x adj ray) radiation)) and (382/151.ccls. 250/559.3.ccls. 356/401.ccls. 356/614.ccls. 348/87.ccls. 348/95.ccls.) not (((align\$4 regist\$6) with (wafer board) with (mask reticle photomask photomask (photo adj mask))) same (xray x-ray (x adj ray))) and (382/151.ccls. 250/559.3.ccls. 356/401.ccls. 356/614.ccls. 348/87.ccls. 348/95.ccls.))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/09 15:14
468	73	((align\$4 regist\$6) with (wafer board) with (mask reticle photomask photomask (photo adj mask))) same (xray x-ray (x adj ray))) and ((project\$3 adj (screen display monitor)) screen display)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/09 16:32
469	1	"3984680".PN.	USPAT	2004/01/09 15:55

470	10	3984680.URPN.	USPAT	2004/01/09 16:23
471	2	((align\$4 regist\$6) with (wafer mask reticle)) same (xray x-ray (x adj ray))) and 3984680.pn.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/01/09 16:33